

<b>Notice of References Cited</b>	Application/Control No. 10/830,035	Applicant(s)/Patent Under Reexamination BOUKHERROUB ET AL.	
	Examiner Mahmoud Dahimene	Art Unit 1765	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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*	B	US-6,284,671	09-2001	Schmuki et al.	438/745
*	C	US-2002/0158256	10-2002	Yamada et al.	257/79
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	E	US-			
	F	US-			
	G	US-			
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	I	US-			
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	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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